

Receipt date: 03/30/2005 <div style="border: 1px solid black; border-radius: 50%; width: 100px; height: 100px; display: flex; align-items: center; justify-content: center; margin: 10px auto;"> <div style="text-align: center;"> <b>U.S. PATENT &amp; TRADEMARK OFFICE</b>  <b>MAR 30 2005</b> </div> </div>	<table border="1" style="width:100%; border-collapse: collapse;"> <tr> <td style="width:50%;">Docket Number (Optional) <b>YKI-0060</b></td> <td style="width:50%;">Registration Number <b>09748470 - GAU: 2879</b> <small>09/748,470</small></td> </tr> <tr> <td colspan="2">Applicant(s) <b>Yamada et al.</b></td> </tr> <tr> <td>Filing Date <b>12/26/2000</b></td> <td>Group Art Unit <b>2879</b></td> </tr> </table>	Docket Number (Optional) <b>YKI-0060</b>	Registration Number <b>09748470 - GAU: 2879</b> <small>09/748,470</small>	Applicant(s) <b>Yamada et al.</b>		Filing Date <b>12/26/2000</b>	Group Art Unit <b>2879</b>
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**U.S. PATENT DOCUMENTS**

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

**U.S. PATENT APPLICATION PUBLICATIONS**

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**FOREIGN PATENT DOCUMENTS**

	REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
							YES	NO
		<b>JP 2000-181086</b>	<b>06/30/2000</b>	<b>Japan</b>				

**OTHER DOCUMENTS** *(Including Author, Title, Date, Pertinent Pages, Etc.)*

		Office Action for Chinese Patent Application No. 011436867

EXAMINER <div style="text-align: center;">/Mariceli Santiago/</div>	DATE CONSIDERED <div style="text-align: center;">01/12/2011</div>
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EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.